

# LOW NOISE LOW DRIFT MONOLITHIC DUAL SILICON NITROX® FIELD EFFECT TRANSISTORS

DIFFUSED ISOLATED

- LOW NOISE .....  $e_n = 8\text{nV}/\sqrt{\text{Hz}}$  TYP.
- LOW LEAKAGE .....  $I_G = 50\text{pA}$  max.
- LOW DRIFT .....  $\left| \frac{\Delta V_{GS_{1-2}}}{\Delta T} \right| = 5\mu\text{V}/^\circ\text{C}$  max.
- LOW OFFSET VOLTAGE .....  $|V_{GS_{1-2}}| = 5\text{mV}$  max.
- LINEAR TEMPERATURE TRACKING TDN =  $\pm 1\mu\text{V}/^\circ\text{C}$

### ABSOLUTE MAXIMUM RATINGS (Note 1)

@ 25°C (unless otherwise noted)

#### Maximum Temperatures

Storage Temperature	-65°	to	+150°C
Operating Junction Temperature			+150°C
Lead Temperature (Soldering, 10 second time limit)			+300°C

#### Maximum Power Dissipation

Device Dissipation @ Free Air-Total	400mW
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#### Maximum Voltage and Current for Each Transistor

$-V_{GSS}$	Gate to Drain or Source Voltage	60V
$-V_{DS0}$	Drain to Source Voltage	60V
$-I_{G(f)}$	Forward Current	50mA

### ELECTRICAL CHARACTERISTICS @ 25°C (unless otherwise noted)

SYMBOL	CHARACTERISTICS	MP 840	MP 841	MP 842	UNITS	CONDITIONS
$\left  \frac{\Delta V_{GS_{1-2}}}{\Delta T} \right $ max.	Drift vs Temperature	5	10	40	$\mu\text{V}/^\circ\text{C}$	$V_{DG} = 20\text{V}, I_D = 200\mu\text{A}$ $T_A = -55^\circ\text{C to } +25^\circ\text{C to } +125^\circ\text{C}$
$ V_{GS_{1-2}} $ max.	Offset Voltage, +25°C	5	5	25	mV	
TDN typ	Temp Drift Nonlinearity	$\pm 1$	$\pm 1$	$\pm 1$	$\mu\text{V}/^\circ\text{C}$	$\left\{ \begin{array}{l} V_{DG} = 20\text{V}, I_D = 200\mu\text{A} \\ T_A = -55^\circ\text{C to } +25^\circ\text{C to } +125^\circ\text{C} \end{array} \right.$
TDN max.		$\pm 3$	$\pm 3$	$\pm 3$	$\mu\text{V}/^\circ\text{C}$	

## ELECTRICAL CHARACTERISTICS @ 25°C (unless otherwise noted)

SYMBOL	CHARACTERISTICS	MN.	TYP.	MAX.	UNITS	CONDITIONS
$\frac{Y_{fs}}{Y_f}$	Transconductance Full Conduction Typical Operation	1000	4000		μmho	$V_{DG} = 20V, V_{GS} = 0, f = 1kHz$ $V_{DG} = 20V, I_D = 200μA$
$\frac{Y_{f_1-2}}{Y_f}$		500	1000		μmho	
$\frac{Y_{f_1-2}}{Y_{fs}}$		—	0.6	3	%	
$I_{DSS}$	Drain Current Full Conduction	0.5	2	5	mA	$V_{DG} = 20V, V_{GS} = 0$
$\frac{I_{DSS_{L-3}}}{I_{DSS}}$		—	1	5	%	
$-I_G$	Gate Current Operating High Temperature Reduced $V_{DG}$ Forward Current At Full Conduction	—	10	50	pA	$V_{DG} = 20V, I_D = 200μA$ $V_{DG} = 20V, I_D = 200μA, T_A = +125°C$ $V_{DG} = 10V, I_D = 200μA$ Any Condition $V_{DG} = 20V, V_{DS} = 0$
$-I_G$		—	—	50	nA	
$-I_G$		—	5	—	pA	
$I_G (I) D^*$		—	—	50	mA	
$-I_{GSS}$		—	—	100	pA	
$Y_{os}$	Output Conductance Full Conduction Operating	—	—	10	μmho	$V_{DG} = 20V, V_{GS} = 0$ $V_{DG} = 20V, I_D = 200μA$
$Y_{os}$		—	0.1	1	μmho	
$ Y_{os_{L-3}} $		—	0.01	0.1	μmho	
CMR	Common Mode Rejection $-20 \log \left  \frac{\Delta V_{GS_{L-1}}}{\Delta V_{DS}} \right $	—	100	—	dB	$\Delta V_{DS} = 10 \text{ to } 20V, I_D = 200μA$ $\Delta V_{DS} = 5 \text{ to } 10V, I_D = 200μA$
		—	75	—	dB	
$V_{GS(\text{off})}$ or $V_P$ $V_{GS}$ $BV_{GSS}$ $V_{GSS\ 0^*}$ $V_{GGD}$	Gate Voltage Pinchoff Voltage Operating Range Breakdown Voltage To Source or Drain Gate-to-Gate Breakdown	1	2	4.5	V	$V_{DS} = 20V, I_D = 1nA$ $V_{DS} = 20V, I_D = 200μA$ $V_{DS} = 0, I_D = 1nA$ Any Condition $I_G = 1nA, I_D = 0, I_S = 0$
		0.5	—	4	V	
		60	—	—	V	
		—	—	60	V	
		60	—	—	V	
		—	—	60	V	
$V_{DS\ 0^*}$	Drain-Source Voltage	—	—	60	V	Any Condition
NF	Noise Figure	—	—	0.5	dB	$V_{DS} = 20V, V_{GS} = 0, R_G = 10MΩ$ $f = 100Hz, NBW = 6Hz$
		—	—	15	$nV/\sqrt{Hz}$	
$\eta_n$	Voltage	—	—	10	$nV/\sqrt{Hz}$	$V_{DS} = 20V, I_D = 200μA, f = 10Hz$ $NBW = 1Hz$ $V_{DS} = 20V, I_D = 200μA, f = 1kHz$ $NBW = 1Hz$
		—	—	—	$nV/\sqrt{Hz}$	
$C_{iss}$ $C_{rss}$ $C_{dd}$	Capacitance Input Reverse Transfer Drain to Drain	—	—	10	pF	$V_{DS} = 20V, I_D = 200μA$ $V_{DG} = 20V, I_D = 200μA$
		—	—	5	pF	
		—	0.1	—	pF	
		—	—	—	$pF$	
$T_S\ 0^*$ $T_J\ 0^*$ $T_L\ 0^*$	Temperature Storage Junction Lead	-65	—	+150	°C	Any Condition Any Condition 10 sec. max. -1/16" or more from case
		—	—	+150	°C	
		—	—	+300	°C	
$P_D\ 0^*$	Dissipation - both sides	—	—	400	mW	$T_A = +25°C, \text{Derate } 3.3mW/°C$

\*Note: These ratings are limiting values above which the serviceability of any semiconductor may be impaired.